## Amendments to the Claims:

The following listing of claims will replace all prior versions, and listings, of claims in the application:

1. (Currently Amended) A method for producing a film, comprising:

discharge device to form said film, the wherein said composition emprises comprising a solvent including at least one heterocyclic compound having one or more substituents and containing an oxygen atom as a constituent atom; and a functional material selected from the group including consisting of conductive materials, insulative materials and semiconductive materials, the at least one heterocyclic compound having one or more substituents excluding a hydrogen atom, containing an oxygen atom as a constituent group, and having a boiling point equal to or greater than 170°C; and

removing the solvent from the composition to form a film.

- 2. (Canceled)
- 3. (Currently Amended) The method for producing a film according to claim 1, further including applying discharging the composition onto the surface of a substrate, and subjecting the substrate carrying the composition to heat treatment and/or pressurization or pressure reduction.
  - 4. (Canceled)
- 5. (Currently Amended) The method for producing a film according to elaim 4claim 1, said functional material including at least an organic electro-luminescence materials material.
  - 6. (Canceled)
- 7. (Currently Amended) The method for producing a film according to claim 1, said at least one heterocyclic compound having including a furan materials.

- 8. (Currently Amended) The method for producing a film according to claim 1, said said at least one heterocyclic compound being 2,3-dihydrodenzofuran2,3-dihydrobenzofuran.
- 9. (Currently Amended) The method for producing a film according to claim 1, said solvent including said <u>at least one</u> heterocyclic compound that further <u>includes including</u> another organic solvent.
- 10. (Currently Amended) The method for producing a film according to claim 9, said solvent including said <u>at least one</u> heterocyclic compound that includes including a benzene derivative.